	Application No.	Application No. Applicant(s)	
Notice of Allowability	10/670,037	BURKE ET AL.	
	Examiner	Art Unit	
	Michael Trinh	2822	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS Is herewith (or previously mailed), a Notice of Allowance (PTOL-8 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.3	S (OR REMAINS) CLOSED in the state of the second of the se	in this application. If not include the same in the include the same in the mailed in due	led course. THIS
1. Mail This communication is responsive to Amendment filed Ju	ne 27, 2005.		
2. The allowed claim(s) is/are <u>1,3,4,6-8 and 10-22</u> .			
3. The drawings filed on 24 September 2003 are accepted to	by the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority of a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority of International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	/e been received. /e been received in Applicati	on No	ation from the
Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	" of this communication to file MENT of this application.	e a reply complying with the re	quirements
5. A SUBSTITUTE OATH OR DECLARATION must be sub- INFORMAL PATENT APPLICATION (PTO-152) which gi			NOTICE OF
 CORRECTED DRAWINGS (as "replacement sheets") muse (a) including changes required by the Notice of Draftspe 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examine Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in 7. DEPOSIT OF and/or INFORMATION about the depattached Examiner's comment regarding REQUIREMENT 	rson's Patent Drawing Revie r's Amendment / Comment o 1.84(c)) should be written on t the header according to 37 Cl osit of BIOLOGICAL MAT	or in the Office action of the drawings in the front (not the FR 1.121(d). ERIAL must be submitted.	
Attachment(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB, Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. Interview S Paper No. 7. Examiner's	Jul	owance Q
			el Trinh Examiner

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DETAILED ACTION

*** This office action is in response to Applicant's Amendment filed June 27, 2005. Claims 2,5,9,23-34 were canceled. Claims 1,3-4,6-8,10-22 are pending.

Allowable Subject Matter

- 1. Claims 1,3-4,6-8,10-22 are allowed.
- 2. The following is a statement of reasons for the indication of allowable subject matter:

In the amendment filed June 27, 2005, Applicant rewrites objected claim 9 into independent form to include all of the limitations of the base claims and any intervening claims. Accordingly, pending claims 1,3-4,6-8,10-22 are allowed for reasons as of record. As of record, the references including Kim (5,851,868), Wu (5,998,264), etc., alone or in combination, do not anticipatively disclose each and every aspect of the claimed capacitive structure, or fairly make a prima facie obvious case of the claimed capacitive structure, in combination with other claimed limitations, and the inclusion of limitations of a polysilicon layer adjacent the first dielectric layer, wherein the well formed within the semiconductor base region, the first dielectric layer, and the first polysilicon layer form a first capacitor and are aligned along a planar dimension; a first conductive layer positioned with at least a portion overlying at least a portion of the polysilicon layer and electrically connected to said polysilicon layer; a second dielectric layer adjacent the first conductive layer; and a second conductive layer adjacent the second dielectric layer with a first electrical connection to said well, wherein the first conductive layer, the second dielectric layer, and the second conductive layer form a second capacitor and are aligned along the planar dimension; and said first electrical connection further comprising: a first metal layer comprising a first region and a second region electrically separate from the first region, wherein the first region is adjacent the second conductive layer; a second metal layer at a distance greater than a distance between the upper surface and the first region of the first metal layer; a second electrical connection between the first region of the first metal layer and the second metal layer; a third electrical connection between the second metal layer and the second region of the first metal layer; and a fourth electrical connection between the second region of the first metal layer and the well.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michael M. Trinh whose telephone number is (571) 272-1847. The examiner can normally be reached on M-F: 8:30 Am to 5:00 Pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on (571) 272-1852. The fax phone numbers for the organization where this application proceeding is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956. Oacs-16

Michael Trinh Primary Examiner